

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Re Patent Application:  
Anguel Nikolov

Serial No.: 10/633,372

Filing Date: August 1, 2003

For: Precision Phase Retardation Devices  
And Method of Making Same

Group Art Unit: 2872

Attorney Docket No.: 02-40171-US

Examiner: Curtis, Craig

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

Applicant submits herewith copies of references or other information of which it is aware that it believes may be material to the examination of this application, and in respect of which, there may be a duty to disclose under 37 C.F.R. § 1.56 and in accordance with 37 C.F.R. §§ 1.97-1.98.

The filing of this information disclosure statement shall not be construed as a representation that a search has been made (37 C.F.R. 1.97(g)), an admission that the information cited is, or is considered to be, material to patentability, or that no other material information may or may not exist.

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Date of Deposit July 15, 2004

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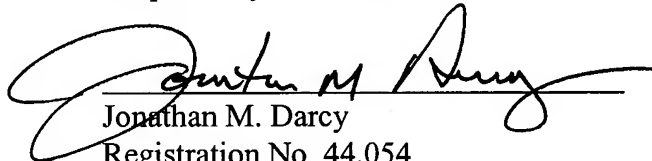
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The Examiner is respectfully requested to review the references identified herewith and make them of record in the instant application as required by M.P.E.P. § 609. The Examiner is also requested to initial one copy of Form 1449 and return same to the undersigned.

Respectfully submitted,

A handwritten signature in black ink, appearing to read "Jonathan M. Darcy", is written over a horizontal line.

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Enclosures: PTO Form 1449  
References

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(37 CFR 1.98(b))

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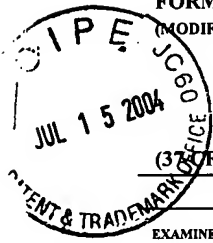
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